## What is claimed is:

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- 1. A process for the production of chlorodifluoroacetyl fluoride which comprises reacting a solvent solution of chlorotrifluoroethylene with oxygen in a reactor to form a product which comprises chlorodifluoroacetyl fluoride.
- 2. The process of claim 1 wherein the reacting is conducted in a continuous mode.
- 3. The process of claim 1 wherein the reacting is conducted in a batch mode.
- 4. The process of claim 1 further comprising the subsequent step of removing chlorodifluoroacetyl fluoride from the product.
- 5. The process of claim 1 further comprising the subsequent step of removing residual solvent from the product, forming a mixture of the residual solvent with additional chlorotrifluoroethylene and recycling the mixture to the reactor.
  - 6. The process of claim 1 wherein the solvent is selected from the group consisting of halogenated butanes, halogenated hexanes, dimethyl cyclobutanes, octadecafluorodecahydronaphthalene, and combinations thereof.
  - 7. The process of claim 1 wherein the solvent is selected from the group consisting of  $C_4F_xCl_y$  wherein x = 1 to 10 and y = 10 x;  $C_6F_xCl_y$  wherein x = 1 to 14 and y = 14 x;  $C_6F_xCl_y$  wherein x = 1 to 12 and y = 12 x; and combinations thereof.

- 8. The process of claim 1 wherein the chlorotrifluoroethylene concentration in the solvent ranges from about 1% to about 30% by weight.
- 9. The process of claim 1 wherein the solvent solution is fed into the reactor at a rate which ranges from about 0.1 to about 3 times the reactor volume per hour.
- 10. The process of claim 1 wherein if the reactor has vapor space, the amount of chlorotrifluoroethylene in the vapor space is maintained at about less than 3 wt.%.
- 11. The process of claim 1 wherein the reaction is conducted at a temperature in the range of from about 20°C to about 200°C.

- 12. The process of claim 1 wherein the oxygen partial pressure is maintained in the range of from about 10 psia about to 300 psia.
- 13. The process of claim 1 wherein the ratio of oxygen to chlorotrifluoroethylene ranges from about 0.01 to about 0.55 by weight.
- 14. A continuous process for the production of chlorodifluoroacetyl fluoride which comprises reacting a solvent solution of chlorotrifluoroethylene with gaseous oxygen with simultaneous agitation in a reactor to form a product which comprises chlorodifluoroacetyl fluoride.
- 15. The process of claim 14 wherein the reaction is conducted by continually feeding the solvent solution of chlorotrifluoroethylene into the reactor, wherein the reactor is pre-pressurized with oxygen.

- 16. The process of claim 14 further comprising the subsequent step of removing chlorodifluoroacetyl fluoride from the product.
- 17. The process of claim 14 further comprising the subsequent step of removing residual solvent from the product, forming a mixture of the residual solvent with additional chlorotrifluoroethylene and recycling the mixture to the reactor.
  - 18. The process of claim 14 wherein the solvent is selected from the group consisting of halogenated butanes, halogenated hexanes, dimethyl cyclobutanes, octadecafluorodecahydronaphthalene, and combinations thereof.

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- 19. The process of claim 14 wherein the solvent is selected from the group consisting of  $C_4F_xCl_y$  wherein x = 1 to 10 and y = 10 x;  $C_6F_xCl_y$  wherein x = 1 to 14 and y = 14 x;  $C_6F_xCl_y$  wherein x = 1 to 12 and y = 12 x; and combinations thereof.
- 20. The process of claim 14 wherein the chlorotrifluoroethylene concentration in the solvent ranges from about 1% to about 30% by weight.
- 21. The process of claim 14 wherein the solvent solution is fed into the reactor at a rate which ranges from about 0.1 to about 3 times the reactor volume per hour.
  - 22. The process of claim 14 wherein if the reactor has vapor space, the amount of chlorotrifluoroethylene in the vapor space is maintained at about less than 3 wt.%.
  - 23. The process of claim 14 wherein the reaction is conducted at a temperature in the range of from about 20°C to about 200°C.

- 24. The process of claim 14 wherein the oxygen partial pressure is maintained in the range of from about 10 psia about to 300 psia.
- 5 25. The process of claim 14 wherein the ratio of oxygen to chlorotrifluoroethylene ranges from about 0.01 to about 0.55 by weight.

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26. A continuous process for the production of chlorodifluoroacetyl fluoride which comprises reacting a solvent solution of chlorotrifluoroethylene with gaseous oxygen with simultaneous agitation in a reactor to form a product which comprises chlorodifluoroacetyl fluoride; wherein the reaction is conducted by continually feeding the solvent solution of chlorotrifluoroethylene into the reactor, wherein the reactor is pre-pressurized with oxygen; and then subsequently removing chlorodifluoroacetyl fluoride from the product; wherein the solvent is selected from the group consisting of halogenated butanes, halogenated hexanes, dimethyl cyclobutanes, octadecafluorodecahydronaphthalene, and combinations thereof; wherein the chlorotrifluoroethylene concentration in the solvent ranges from about 1% to 30% by weight; wherein the solvent solution is fed into the reactor at a rate which ranges from about 0.1 to about 3 times the reactor volume per hour; wherein if the reactor has vapor space, the amount of chlorotrifluoroethylene in the vapor space is maintained at about less than 3 wt.%; wherein the reacting is conducted at a temperature in the range of from about 20°C to about 200°C; wherein the oxygen partial pressure is maintained in the range of from about 10 psia to about 300 psia; wherein the ratio of oxygen to chlorotrifluoroethylene ranges from about 0.01 to about 0.55 by weight.

- 27. The process of claim 26 further comprising the subsequent step of removing residual solvent from the product, forming a mixture of the residual solvent with additional chlorotrifluoroethylene and recycling the mixture to the reactor.
- 28. The process of claim 26 wherein the solvent is selected from the group consisting of  $C_4F_xCl_y$  wherein x = 1 to 10 and y = 10 x;  $C_6F_xCl_y$  wherein x = 1 to 14 and y = 14 x;  $C_6F_xCl_y$  wherein x = 1 to 12 and y = 12 x; and combinations thereof.